

Radiation damage investigation of epitaxial p-type silicon using Schottky and pn-junction diodes

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Focus of this RD50 project is the investigation of trap energy levels introduced by radiation damage in epitaxial p-type silicon. Using 6-inch wafers of various boron doping concentrations ($1e13$, $1e14$, $1e15$, $1e16$, and $1e17$ cm^{-3}) with a $50 \mu\text{m}$ epitaxial layer, multiple iterations of test structures consisting of Schottky and pn-junction diodes of different sizes and flavours are being fabricated at RAL and Carleton University.

Details on the initial fabrication phase of devices on high resistivity wafers will be given. IV and CV scans of test structures have been performed and cross-checked between institutes, the results of which will be presented.

Samples of both Schottky and pn-junction diodes have been further investigated using Deep-Level Transient Spectroscopy (DLTS) and Thermal Admittance Spectroscopy (TAS) to characterise trap energy levels in unirradiated devices.

The findings as well as plans for measurements of irradiated samples will be discussed.

TIPP2020 abstract resubmission?

No, this is an entirely new submission.

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